

Amendments to the Specification:

After the title add the following heading and paragraph:

--RELATED APPLICATIONS

This application is a U.S. Continuation Application under 35 USC 111(a) of International Application No. PCT/JP02/07180 filed July 15, 2002.--

Page 3, replace the paragraph beginning at line 13 with the following amended paragraph:

To attain the above object, according to a first aspect of the present invention, there is provided a semi-transmitting mirror-possessing substrate having a glass substrate, a foundation film formed on the glass substrate, and a semi-transmitting reflective film formed on the foundation film, the semi-transmitting mirror-possessing substrate characterized in that the foundation film has a thickness in a range of 0 to 8nm.

Page 3, between lines 33 and 34, add the following new paragraph

--To attain the above object, according to a second aspect of the present invention, there is provided a semi-transmitting mirror-possessing substrate having a glass substrate, a foundation film formed on the glass substrate, and a semi-transmitting reflective film formed on the foundation film, the semi-transmitting mirror-possessing substrate characterized in that the foundation film is made of silicon oxide having a thickness in a range of 0 to 8nm, a chemical composition ratio x of oxygen (O) to silicon (Si) in the silicon oxide (SiO_x) is in a range of 1.5 to 2.0, and the semi-transmitting reflective film is made of at least one selected from the group consisting of Al and Al alloys.--

Page 3, replace the paragraph bridging pages 3 and 4 with the following amended paragraph:

To attain the above object, according to a ~~second~~ third aspect of the present invention, there is provided a semi-transmitting type liquid crystal display apparatus characterized by having the semi-transmitting mirror-possessing substrate according to the ~~first~~ second aspect of the present invention.

Page 15, between lines 33 and 34 insert the following new paragraph:

--According to the semi-transmitting type liquid crystal display apparatus according to the second aspect of the present invention, if the foundation film is made of silicon oxide having a thickness in a range of 0 to 8nm, a chemical composition ratio x of oxygen (O) to silicon (Si) in the silicon oxide (SiO_x) is in a range of 1.5 to 2.0, and the semi-transmitting reflective film is made of at least one selected from the group consisting of Al and Al alloys, then the reflectivity can be increased while maintaining high transmissivity.--

Page 15, replace the paragraph bridging pages 15 and 16 with the following amended paragraph:

According to the semi-transmitting type liquid crystal display apparatus according to the ~~second~~ third aspect of the present invention, the semi-transmitting type liquid crystal display apparatus has the semi-transmitting mirror-possessing substrate according to the ~~first~~ second aspect of the present invention; as a result, there is high reflectivity while maintaining high transmissivity, and hence a semi-transmitting type liquid crystal display apparatus having both

By Express Mail # EV375318396US

improved transmission display performance and improved reflection display performance can be obtained.